

U.S. Department of Commerce, Patent and Trademark Office	Attorney Docket No.: <b>OIC0099US</b>	Application No.: 10/696,097
INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use several sheets if necessary)	Inventors: Kahlon et al.	Confirmation No.: 6621
	Filing Date: October 28, 2003	Group Art Unit: 3627

### U.S. Patent Documents

*Examiner Initial	Cite No.	Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
/F.O./	1.	5,349,643	Sep. 20, 1994	Cox et al.	380	25	
/F.O./	2.	6,792,431 B2	Sep. 14, 2004	Tamboli et al.	707	102	
/F.O./	3.	7,257,594	Aug. 14, 2007	Tamboli et al.	701	101	

### Patent Application Publication

/F.O./	4.	2002/0040313 A1	Apr. 4, 2002	Hunter et al.	705	9	
/F.O./	5.	2002/0123983 A1	Sep. 5, 2002	Riley et al.	707	1	
/F.O./	6.	2002/0188513 A1	Dec. 12, 2002	Gil et al.	705	22	
/F.O./	7.	2003/0071852 A1	Apr. 17, 2003	Stimac	345	810	
/F.O./	8.	2003/0131018 A1	Jul. 10, 2003	Godoy et al.	707	104.1	
/F.O./	9.	2004/0249854 A1	Dec. 9, 2004	Barnes-Leon, et al.	703	103 Y	
/F.O./	10.	2005/0091249 A1	Apr. 28, 2005	Hanson et al.	707	101	
/F.O./	11.	2005/0197880	Sep. 8, 2005	Walsh et al.	705	8	
/F.O./	12.	2007/0033531 A1	Feb. 8, 2007	Marsh	715	738	

### OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

/F.O./	13.	NPL_XML_Schema_CE.pdf, A tutorial published by the SML governing body of w3.org regarding the use of SML Schemas and Complex Data Elements. Downloaded on 10 June 2009 from <a href="http://www.w3schools.com/Schema/schema_intro.asp?">http://www.w3schools.com/Schema/schema_intro.asp?</a> and <a href="http://www.w3schools.com/Schema/schema_complex_empty.asp?">http://www.w3schools.com/Schema/schema_complex_empty.asp?</a> 7 pages.					
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Examiner: /Fahd Obeid/	Date Considered 12/05/2009
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\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.